

## San Diego State University

## Project Overview

### **Background:**

ASML is the leading provider of EUV (extreme ultraviolet) lithography equipment used in the production of advanced, semiconductor chips worldwide.

As part of troubleshooting, research, and development, ASML employs a heated vacuum chamber to simulate the various operating conditions where the Multilayer Mirror samples are used.

### **Problem Statement:**

Create a water-cooled baseplate capable of holding a variety of mirror shapes and sizes at 30°C - 50°C while exposed to a maximum temperature of 300°C under vacuum.



Soldering Lead Pins



**Cutting Stock Material** 

## Manufacturing



Perfboard Circuit



Machined Baseplate



**3D** Printed Housing



CNC Milling Custom Clamps

## Team Members



Hunter Atchley Lead Engineer



Brenden Funke **Procurement & Research** Engineer





Jorge Pineda Supply & Finance Engineer

# Multilayer Mirror Sample Holder with Cooling





Data Acquisition Validation

## Testing



Heat Resistance & Leak Check On Campus



Full System Validation On Site at ASML



Andrew Preisler Design & Manufacturing Engineer



Aaron Ramirez Quality & Test Engineer

## Acknowledgements

The team would like to thank the following people for their contributions.

ASML:

Joe Bendik - Project Sponsor Tony Balanza - Test Chamber Specialist

### **SDSU:**

Dr. Scott Shaffar - Project Advisor Mike Lester - Manufacturing Assistance Selena Jarin - Purchasing Assistance







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